

# Feipeng Cheng

## List of Publications by Year in descending order

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Version: 2024-02-01

20  
papers

298  
citations

840776

11  
h-index

888059

17  
g-index

20  
all docs

20  
docs citations

20  
times ranked

129  
citing authors

| #  | ARTICLE   | IF   | CITATIONS |
|----|---|------|-----------|
| 1  | Design of NiCo <sub>2</sub> O <sub>4</sub> nanoparticles decorated N, S co-doped reduced graphene oxide composites for electrochemical simultaneous detection of trace multiple heavy metal ions and hydrogen evolution reaction. <i>Chemical Engineering Journal</i> , 2022, 433, 133854.                        | 12.7 | 46        |
| 2  | Fabrication and electrical properties of the fast response Mn <sub>1.2</sub> Co <sub>1.5</sub> Ni <sub>0.3</sub> O <sub>4</sub> miniature NTC chip thermistors. <i>Ceramics International</i> , 2019, 45, 378-383.  | 4.8  | 32        |
| 3  | Epitaxial growth of Mn <sup>2+</sup> Co <sup>2+</sup> Ni <sup>2+</sup> O thin films and thickness effects on the electrical properties. <i>Materials Letters</i> , 2014, 130, 127-130.  | 2.6  | 27        |
| 4  | Effect of sputtering power on structural, cationic distribution and optical properties of Mn <sub>2</sub> Zn <sub>0.25</sub> Ni <sub>0.75</sub> O <sub>4</sub> thin films. <i>Applied Surface Science</i> , 2018, 435, 815-821.   | 6.1  | 27        |
| 5  | Formation of Mn <sup>2+</sup> Co <sup>2+</sup> Ni <sup>2+</sup> O Nanoceramic Microspheres Using In Situ Inkjet Printing: Sintering Process Effect on the Microstructure and Electrical Properties. <i>Small</i> , 2016, 12, 5027-5033.   | 10.0 | 24        |
| 6  | A study on the electrical properties of Mn-Co-Ni-O thin films grown by radio frequency magnetron sputtering with different thicknesses. <i>Applied Surface Science</i> , 2017, 423, 1012-1018.  | 6.1  | 23        |
| 7  | Effects of preferred orientation on electrical properties of Mn <sub>1.56</sub> Co <sub>0.96</sub> Ni <sub>0.48</sub> O <sub>4</sub> spinel films. <i>Materials Letters</i> , 2014, 137, 36-40.   | 2.6  | 21        |
| 8  | High B value Mn-Co-Ni spinel films on alumina substrate by RF sputtering. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 9876-9881.  | 2.2  | 16        |
| 9  | Influence of oxygen atmosphere annealing on the thermal stability of Mn <sub>1.2</sub> Co <sub>1.5</sub> Ni <sub>0.3</sub> O <sub>4</sub> ceramic films fabricated by RF magnetron sputtering. <i>Ceramics International</i> , 2018, 44, 1455-1460.   | 4.8  | 15        |
| 10 | Mn <sub>1.56</sub> Co <sub>0.96</sub> Ni <sub>0.48</sub> O <sub>4</sub> flexible thin films fabricated by pulsed laser deposition for NTC applications. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2016, 206, 39-44.   | 3.5  | 14        |
| 11 | Characterization of Al-doped Mn <sup>2+</sup> Co <sup>2+</sup> Ni <sup>2+</sup> O NTC thermistor films prepared by the magnetron co-sputtering approach. <i>Journal of Alloys and Compounds</i> , 2020, 831, 154831.  | 5.5  | 13        |
| 12 | A novel NTC ceramic based on La <sub>2</sub> Zr <sub>2</sub> O <sub>7</sub> for high-temperature thermistor. <i>Journal of the European Ceramic Society</i> , 2022, 42, 2561-2564.  | 5.7  | 9         |
| 13 | Oxidation mode on charge transfer mechanism in formation of Mn <sup>2+</sup> Co <sup>2+</sup> Ni <sup>2+</sup> O spinel films by RF sputtering. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 13659-13664.  | 2.2  | 7         |
| 14 | Improvement of Mn <sub>1.56</sub> (Co <sub>1-x</sub> Al <sub>x</sub> ) <sub>0.96</sub> Ni <sub>0.48</sub> O <sub>4</sub> (0.1 ≤ x ≤ 0.4) Film Preparation and Assessment of Its Structure and Properties. <i>Journal of Electronic Materials</i> , 2019, 48, 2077-2084.   | 2.2  | 5         |
| 15 | Improvement of electrical properties of single-phase film thermistors by a Ni <sub>0.75</sub> Mn <sub>2.25</sub> O <sub>4</sub> /LaMnO <sub>3</sub> bilayer structure. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 3837-3842.   | 2.2  | 4         |
| 16 | Fabrication and properties of high B value [Mn <sub>1.56</sub> Co <sub>0.96</sub> Ni <sub>0.48</sub> O <sub>4</sub> ] <sub>1-x</sub> [SrMnO <sub>3</sub> ] <sub>x</sub> (0 ≤ x ≤ 0.5) spinel-perovskite composite NTC films. <i>Journal of Materials Science: Materials in Electronics</i> , 2018, 29, 9613-9620. | 2.2  | 4         |
| 17 | Effect of substrate temperature on structure, cationic distribution and electrical properties of MnCo <sub>0.2</sub> Ni <sub>0.1</sub> Mg <sub>0.6</sub> Al <sub>1.1</sub> O <sub>4</sub> thin films. <i>Journal of Materials Science: Materials in Electronics</i> , 2019, 30, 14200-14206.                      | 2.2  | 4         |
| 18 | Growth mode and properties of Mn <sup>2+</sup> Co <sup>2+</sup> Ni <sup>2+</sup> O NTC thermistor thin films deposited on MgO (100) substrate by laser MBE. <i>Modern Physics Letters B</i> , 2014, 28, 1450235.  | 1.9  | 3         |

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|----|--|-----|-----------|
| 19 | Effect of sintering temperature on structural and electrical properties of Mn <sub>0.55</sub> Fe <sub>1.25</sub> Cu <sub>2</sub> Ni <sub>2.2</sub> O <sub>4</sub> + $\hat{r}$ NTC thick film. Journal of Materials Science: Materials in Electronics, 2020, 31, 12848-12855. | 2.2 | 3         |
| 20 | Substrate-induced morphology and its effect on the electrical properties and stability of polycrystalline Mn <sub>1.2</sub> Co <sub>1.5</sub> Ni <sub>0.3</sub> O <sub>4</sub> thin films. Journal of Materials Science: Materials in Electronics, 2021, 32, 22588-22598.    | 2.2 | 1         |